

QCVN 19: 2009 National Technical Regulation on Industrial Emission of Inorganic Substances and**Dusts****Max allowable concentration of dust and inorganic substance in industrial emission**

No	Parameters	Concentration C (mg/Nm ³)
1	Total particle	200
2	Dust containing silicon	50
3	Ammoniac and its compounds	50
4	Antimon and its compounds, base on Sb	10
5	Arsenic and its compounds, base on As	10
6	Cadmium and its compounds, base on Cd	5
7	Lead and its compounds, base on Pb	5
8	CO	1000
9	Chlorine	10
10	Copper and its compounds, base on Cu	10
11	Zinc and its compounds, base on Zn	30
12	HCl	50
13	Flo, HF, or inorganic compounds of Flo, base on HF	20
14	H ₂ S	7,5
15	SO ₂	500
16	NO _x , base on NO ₂	850
17	NO _x (acid manufacturers), base on NO ₂	1000
18	Vapor of H ₂ SO ₄ or SO ₃ , base on SO ₃	50
19	Vapor of HNO ₃ (other sources), base on NO ₂	500